

Masked Spiking Transformer

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Motivation

- Performance Gap between ANNs and SNNs: SNNs are efficient at processing sparse data on neuromorphic hardware but currently lag behind ANNs in performance on complex tasks.
- High delay and energy consumption **ANN-to-SNN** conversion method: OT ANN-to-SNN conversion methods convert ANNs into SNNs for pre-trained better performance while requiring more simulation power increased steps, with consumption to reduce conversion error.

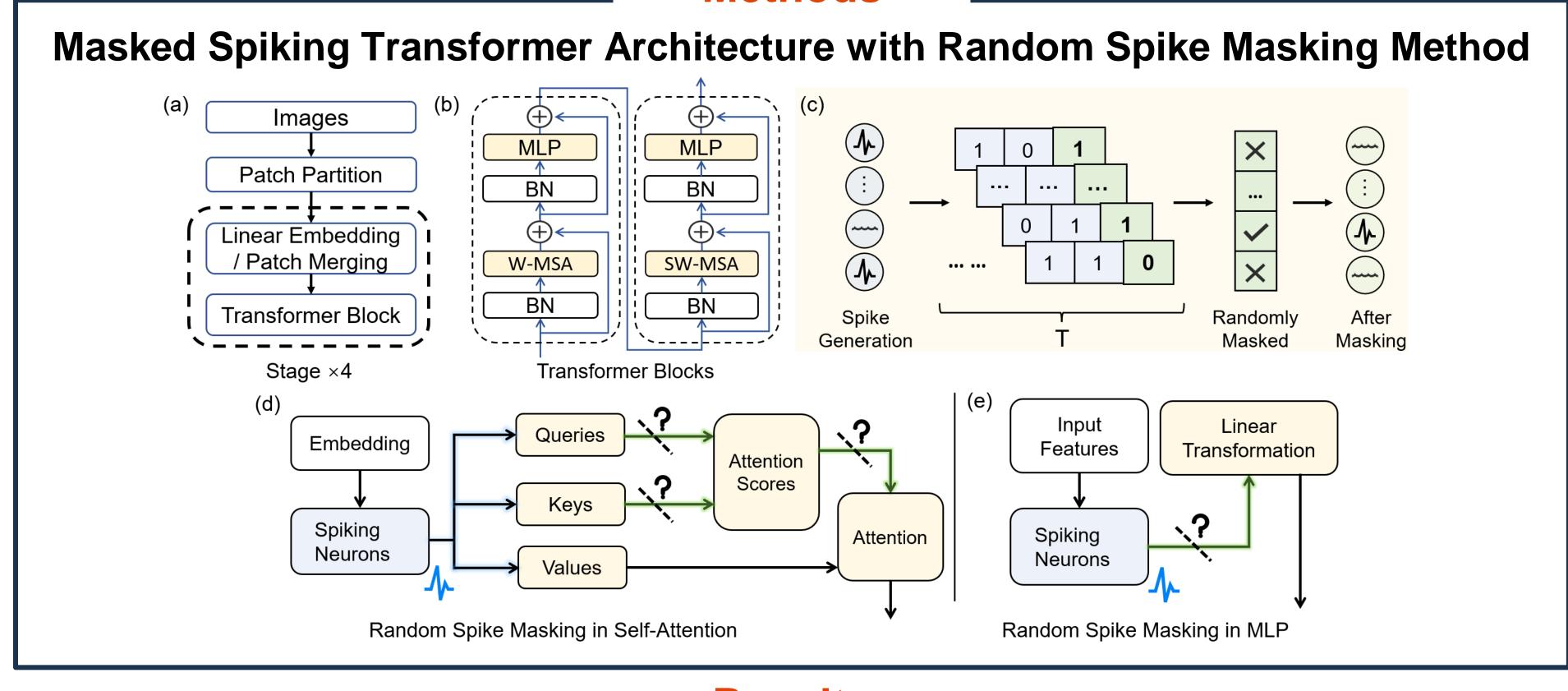
Contributions

- Masked Spiking Transformer based on ANN-to-SNN conversion methods: the first exploration of fully implementing the self-attention mechanism in SNNs using ANN-to-SNN conversion methods
- Masking Method Random for efficiency: improving bioenergy inspired spike pruning to reduce redundant synaptic operations

Evaluation

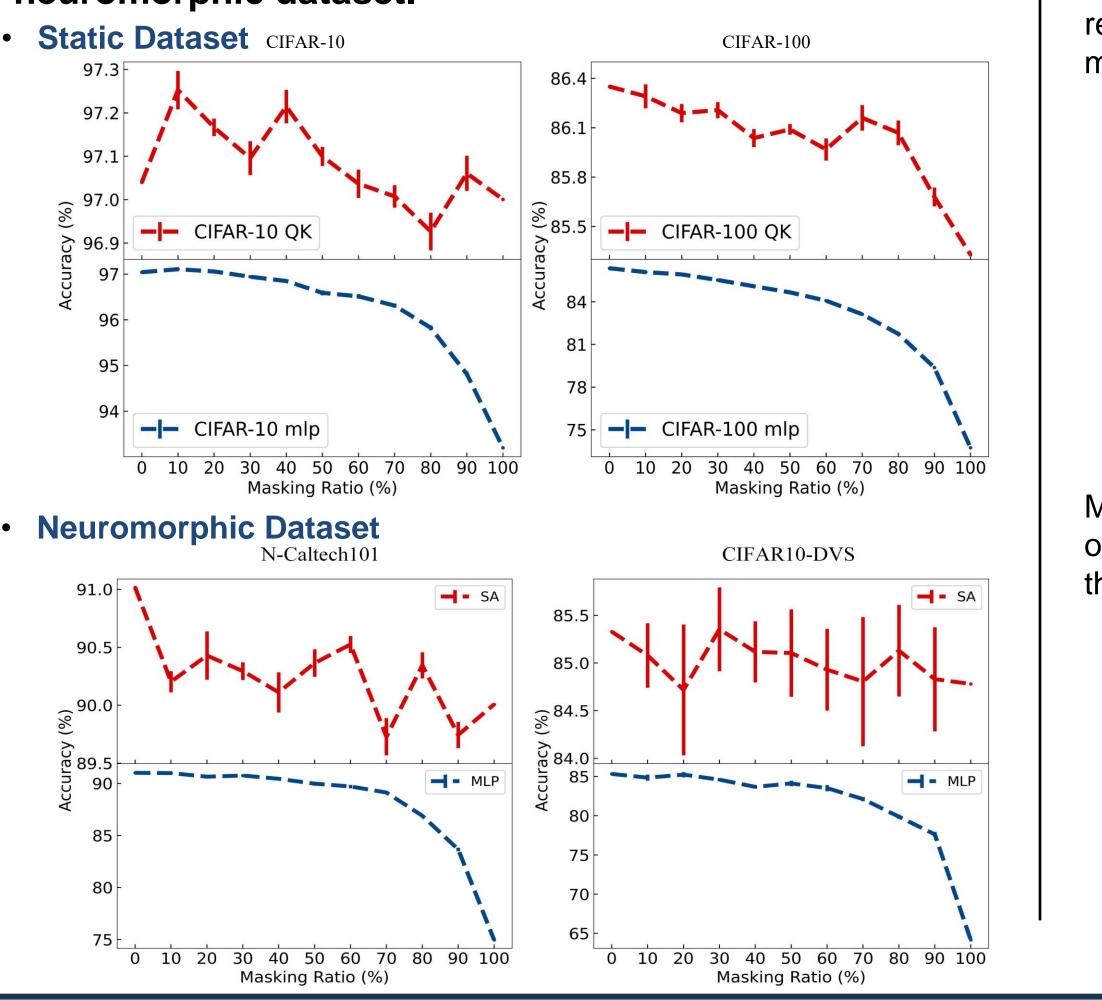
- The performance of the Masked Spiking ulletTransformer model was evaluated on both static and neuromorphic datasets.
- The effectiveness of the Random Spike Masking method was evaluated across various masking configurations and model architectures, using spike count as an indicator of energy efficiency.

Methods



Results

1) The MST model that combines self-attention mechanism and ANN-to-SNN conversion methods achieves SOTA top-1 accuracy on both static and neuromorphic dataset.





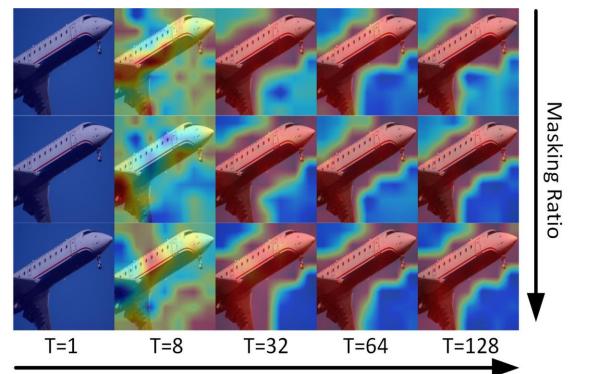


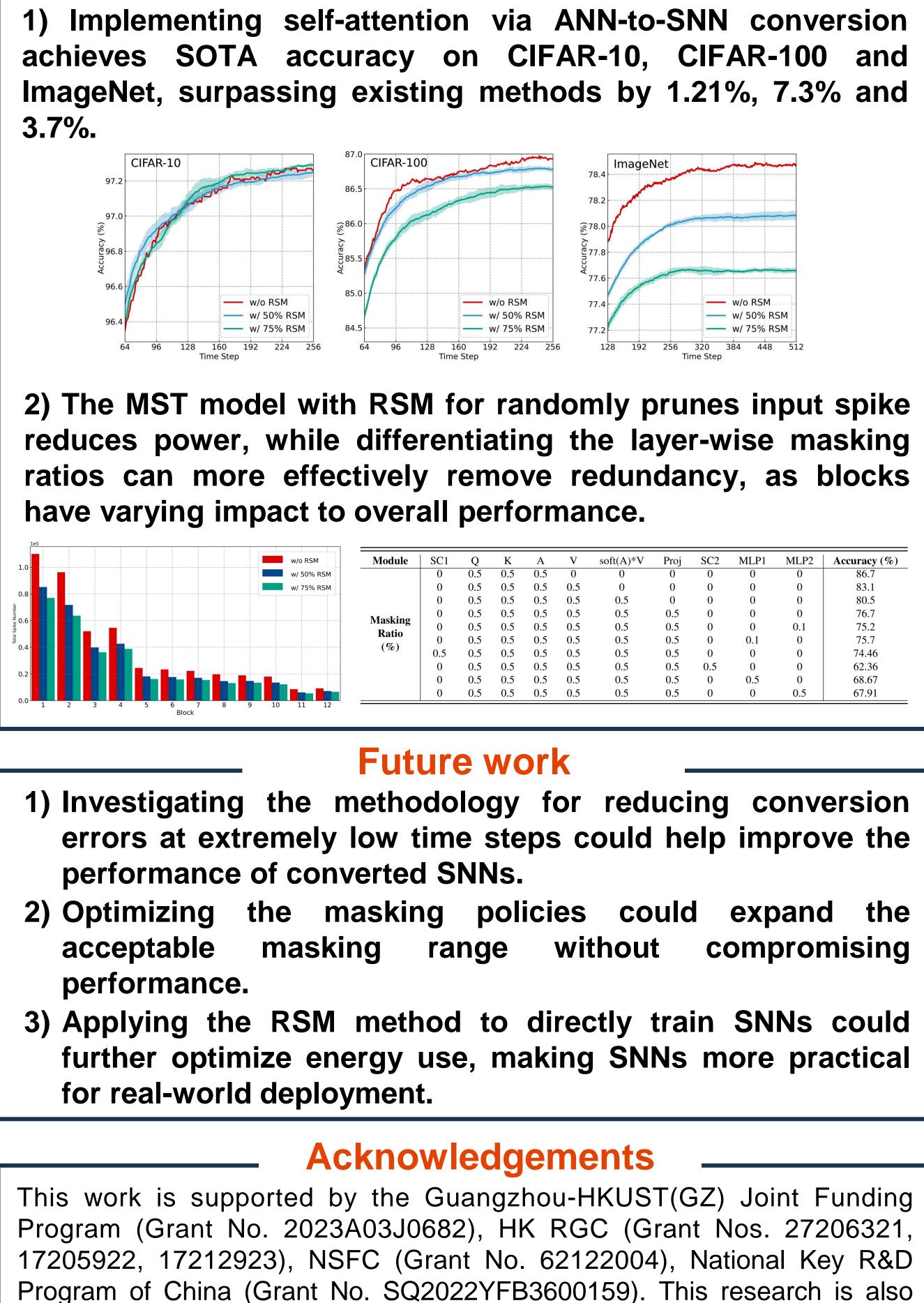
2) The RSM method reduces redundant spike operations while keeping model performance over a certain range of mask rates. For instance, the RSM method reduces MST model power by 26.8% at a 75% mask rate with no performance drop.

Model	Random Ratio	P (α Watts)	Accuracy (%)
	0%	3.9G (×1)	97.27 (+0)
MST	50%	3.2G (×0.82)	97.25 (-0.02)
	75%	2.9G (×0.74)	97.29 (+0.02)
ResNet-18	0%	58.2M (×1)	96.48 (+0)
	50%	40.7M (×0.70)	92.88 (-3.60)
	75%	34.1M (×0.58)	82.68 (-13.80)
VGG-16	0%	24.4M (×1)	95.46 (+0)
	50%	18.9M (×0.77)	89.56 (-5.90)
	75%	16.7M (×0.68)	79.09 (-16.37)

Models with varying mask rates focus on similar object regions at the same time step, as shown by the red outlines.







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Conclusion

/o RSM	Module	SC1	Q	Κ	Α	V	soft(A)*V	Proj	SC2	MLP1	MLP2	Accuracy (%)
/ 50% RSM	Masking Ratio (%)	0	0.5	0.5	0.5	0	0	0	0	0	0	86.7
/ 75% RSM		0	0.5	0.5	0.5	0.5	0	0	0	0	0	83.1
		0	0.5	0.5	0.5	0.5	0.5	0	0	0	0	80.5
		0	0.5	0.5	0.5	0.5	0.5	0.5	0	0	0	76.7
		0	0.5	0.5	0.5	0.5	0.5	0.5	0	0	0.1	75.2
		0	0.5	0.5	0.5	0.5	0.5	0.5	0	0.1	0	75.7
		0.5	0.5	0.5	0.5	0.5	0.5	0.5	0	0	0	74.46
		0	0.5	0.5	0.5	0.5	0.5	0.5	0.5	0	0	62.36
		0	0.5	0.5	0.5	0.5	0.5	0.5	0	0.5	0	68.67
		0	0.5	0.5	0.5	0.5	0.5	0.5	0	0	0.5	67.91

compromising